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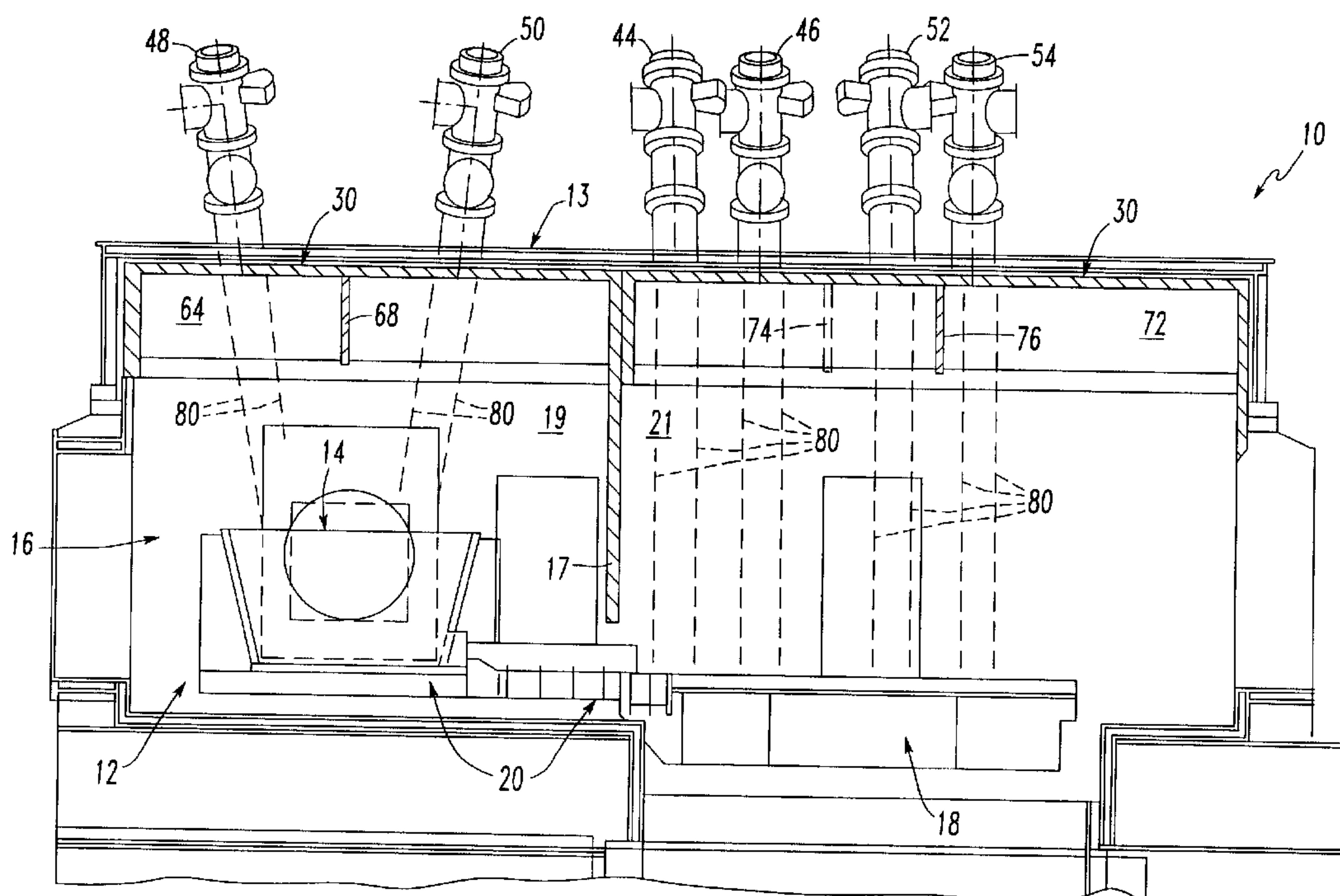
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FAISCEAUX ELECTRONIQUES
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(57) Abrégé/Abstract:

An apparatus for limiting interaction of electron beams produced by adjacent electron beam guns (54) mounted within a vacuum chamber (12) of a furnace (10). The apparatus includes suspending one or more barriers (76, 68) within the vacuum chamber (12) between adjacent electron beam guns (54).

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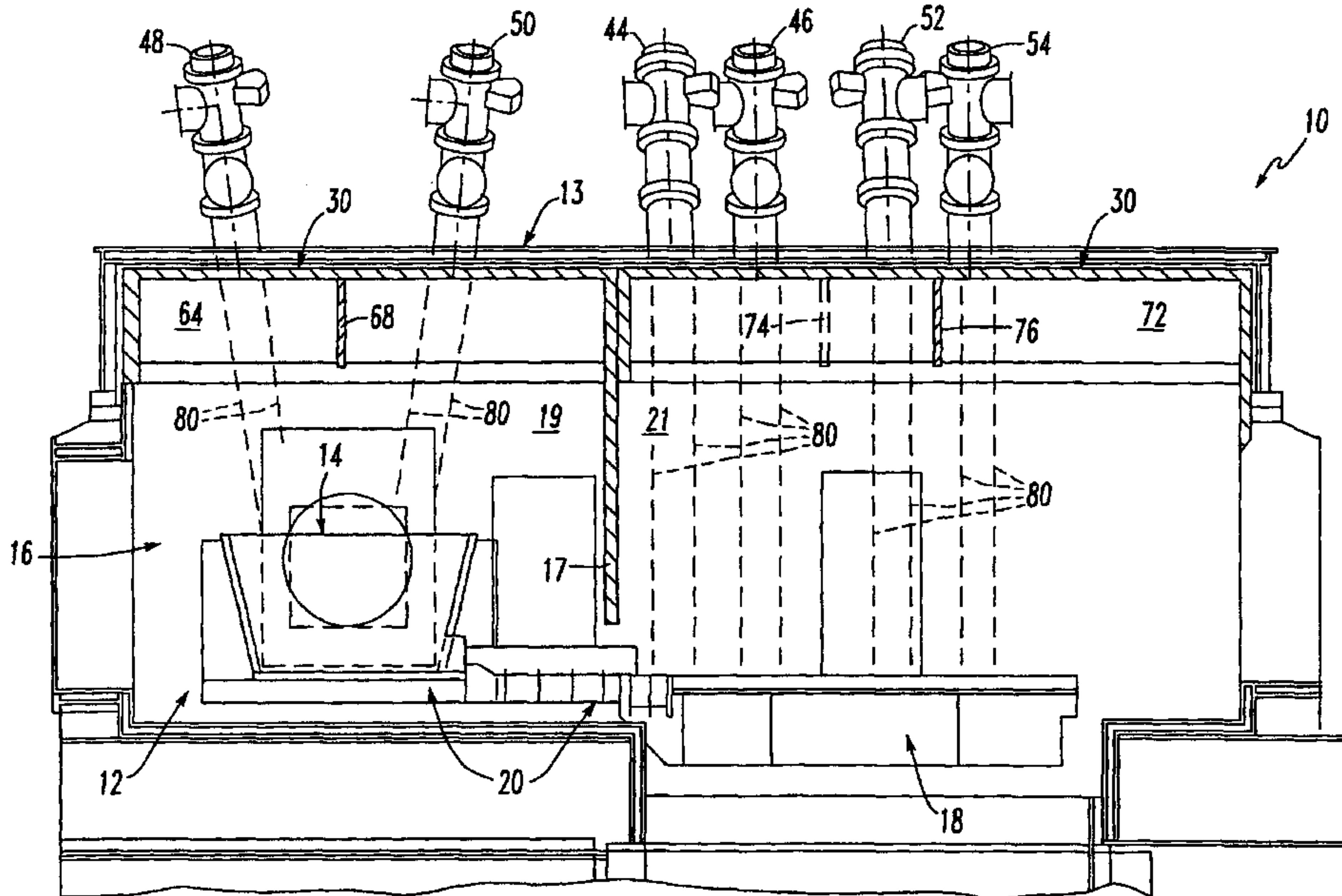
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TITLE

ELECTRON BEAM SHIELDING APPARATUS AND METHODS FOR
SHIELDING ELECTRON BEAMS

5

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15

CROSS-REFERENCE TO RELATED APPLICATIONS

Not applicable.

FEDERALLY SPONSORED RESEARCH

Not applicable.

20

BACKGROUND OF THE INVENTION

FIELD OF THE INVENTION

The subject invention relates to electron beam furnaces
25 for processing metallic materials and, more particularly, to
apparatuses and methods for controlling and limiting the
interaction of electron beams generated by adjacent electron
beam guns mounted within an electron beam furnace.

30 DESCRIPTION OF THE INVENTION BACKGROUND

A variety of different processes and apparatuses have

been developed over the years for obtaining relatively pure metals or alloys. One such apparatus that has been developed to separate the slag and burn off or evaporate volatile impurities from molten metal material is known as an electron 5 beam furnace. Such furnaces are disclosed, for example, in U.S. Patent No. 4,027,722 to Hunt and U.S. Patent No. 4,932,635 to Harker.

In general, an electron beam furnace includes a vacuum chamber that has a hearth and crucible system therein. A 10 number of electron beam guns are typically mounted in the vacuum chamber above the hearth to melt metals that are introduced into the chamber. As the metal is melted, it flows into the crucible to be re-solidified into an ingot. The electron beam from each gun can be deflected and scanned 15 over the surfaces of the metal. The deflection of the electron beam is typically controlled by computers and electromagnetic coils in the base of each electron beam gun which serve to deflect the beam in accordance with changes in the magnetic fields. The use and construction of such 20 electron beam guns are known in the art as exemplified by those electron beam guns disclosed in U.S. Patent No. 3,857,014 to Prudkovsky et al. and U.S. Patent No. RE 35,024 to Hanks.

The generation of electron beams by multiple electron 25 beam guns in close proximity to each other can result in undesirable electromagnetic interaction between the beams. Changes in deflection or beam power of one gun can cause a change of deflection in an adjacent gun, which also

influences the gun adjacent to it and so on. That interaction can make it difficult to control the beams to obtain the desired result. In addition, because the interaction of the electron beams is largely a function of 5 the location of the electron beam guns relative to each other within the vacuum chamber, the further away from the metal that the electron guns are located, the greater the likelihood of electron beam interaction. Thus, the size of the vacuum chamber is often dictated by the number and 10 location of electron beam guns. Small vacuum chambers require more frequent cleaning to remove the buildup of condensate material therein that could hamper and possibly lead to contamination of the material passing therein.

Thus, there is a need for apparatuses and methods for 15 limiting the interaction between beams of adjacently mounted electron beam guns.

There is a further need for apparatuses and methods for improving the ability to control electron beam guns within an electron beam furnace.

20 There is still another need for apparatus having the above-mentioned advantages that is relatively inexpensive to manufacture and install.

Another need exists for an electron beam furnace that has means for limiting the interaction between the beams 25 generated by electron beam guns mounted therein.

SUMMARY OF THE INVENTION

In accordance with a particularly preferred form of the

present invention, there is provided an apparatus for limiting interaction between beams generated by at least two electron beam guns mounted within an electron beam furnace having a superstructure. The apparatus may include a planar 5 barrier sized to extend between at least two electron beam guns and a superstructure hanger connected to the planar barrier.

The subject invention may also comprise an electron beam furnace that includes a vacuum chamber that has an upper 10 portion and a lower portion. The furnace also has a hearth assembly located within the lower portion of said vacuum chamber and at least two electron beam guns mounted within the vacuum chamber above the hearth assembly. In addition, the furnace includes at least one planar barrier suspended 15 from the upper portion of the vacuum chamber such that it extends between at least two electron beam guns.

The subject invention may also comprise a method for limiting interaction between electron beams generated by at least two electron beam guns within a vacuum chamber of an 20 electron beam furnace. The method includes suspending a barrier from an upper portion of the vacuum chamber such that the barrier extends between the electron beams produced by the electron beam guns.

It is a feature of the present invention to provide 25 magnetic shield barriers within an electron beam furnace to limit undesirable interaction between the beams of adjacent guns.

It is another feature of the present invention to

provide magnetic shield barriers that are relatively inexpensive to manufacture and install.

Yet another feature of the present invention is to provide magnetic shield barriers that enable the electron 5 beam guns to be positioned farther from their targets which enables larger vacuum chambers to be employed in electron beam furnaces. Larger chambers reduce the frequency of clean-outs required because the condensate collection can be placed further away from the melting process and can be 10 provided with a larger surface area which results in a slower buildup of condensate. Accordingly, the present invention provides solutions to the shortcomings of prior furnaces that employ electron beam guns. Those of ordinary skill in the art will readily appreciate, however, that these and other 15 details, features and advantages will become further apparent as the following detailed description of the preferred embodiments proceeds.

BRIEF DESCRIPTION OF THE DRAWINGS

20 In the accompanying Figures, there are shown present preferred embodiments of the invention wherein like reference numerals are employed to designate like parts and wherein:

FIG. 1 is a partial cross-sectional elevational view of a portion of an electron beam furnace employing shield 25 assemblies of the present invention;

FIG. 2 is a partial cross-sectional end view of the furnace of Figure 1;

FIG. 3 is a partial plan view of the furnace of Figures

1 and 2, illustrating the orientation of the shield assemblies relative to the electron beam guns;

FIG. 4 is a partial plan view of another electron beam furnace employing another shield assembly embodiment of the 5 present invention;

FIG. 5 is a side elevational view of the shield assembly depicted in Figure 4;

FIG. 6 is a top view of the shield assembly of Figure 5;

FIG. 7 is an end view of the shield assembly of Figures 10 5 and 6;

FIG. 8 is an enlarged partial view showing the struts of the shield assembly attached to the longitudinal barrier; and

FIG. 9 is an end elevational view of the furnace of Figure 4, showing a transverse endplate of the subject 15 invention attached to the condensate assembly of the furnace.

DETAILED DESCRIPTION OF THE PREFERRED EMBODIMENTS

Referring now to the drawings for the purposes of illustrating the present preferred embodiments of the 20 invention only and not for the purposes of limiting the same, Figures 1-3 show an electron beam furnace 10 for melting metals that has a shield assembly 60 of the present invention installed therein. Those of ordinary skill in the art will appreciate that the shield assembly 60 may be successfully 25 employed in connection with a variety of different electron beam furnace configurations. Thus, the present invention should not be limited to use only in connection with furnaces that are constructed the manner depicted in the present

Figures and described herein.

More specifically and with reference to Figures 1 and 2, the furnace 10 includes a vacuum chamber 12 that has a hearth assembly 20 extending therethrough. The vacuum chamber 12 has an entry end 14 into which raw material is introduced, a melting zone 16, and a crucible mold 18. In practice, molten material flows along the hearth assembly 20 under the influence of gravity. Raw material is introduced into the entry end 14. The raw material is melted by bombarding it with beams of charged particles from a series of electron beam guns (40, 42, 44, 46, 48, 50, 52, 54) mounted within the vacuum chamber 12 above the hearth assembly 20. The molten material flows in one continuous path through the hearth assembly 20 into the crucible mold 18. It will be understood that by heating the molten material flowing along the hearth assembly 20 and by maintaining a relatively high vacuum, various volatile impurities and occluded gases emitted from the molten metal are exhausted from the chamber 12 through the vacuum pumps (not shown) servicing the chamber 12. Thus, the molten material is purified as it flows through the melting zone 16 such that it achieves the desired level of purity when it reaches the crucible mold 18. From the crucible mold 18, the molten material is then continuously cast into a cold mold or the like in a casting zone which facilitates the continuous egress of material from the furnace in the form of, for example, metal ingots.

As the molten metal is heated within the processing zone, some metal is deposited on the interior walls and

structures within the vacuum chamber 12. After a predetermined period of time, the process must be interrupted to permit cleaning of the vacuum chamber 12. The vacuum chamber 12 is typically provided with a series of condensate frame assemblies 30 that are supported from the upper superstructure 13 of the vacuum chamber 12. See Figures 1 and 2. Such condensate frame assemblies 30 may be fabricated from, for example, mild steel and have a series of screens, plates, etc. that provide surfaces upon which the molten metal may adhere. Removing the excess material from the condensate frame assembly 30 can be an arduous task. Often times the excess material must be chiseled or ground from the condensate screens. Thus, to minimize the amount of downtime associated with cleaning the vacuum chamber 12, the condensate frame assemblies 30 are typically constructed so that they may be removed from the vacuum chamber 12 and replaced with clean frame assemblies 30 to permit the contaminated frame assemblies 30 to be cleaned off line.

As discussed above, a series of conventional electron beam guns are mounted above the hearth assembly 20 to direct electron particle beams onto the molten material thereon. The furnace 10 depicted in Figures 1-3 has a total of eight conventional electron beam guns (40, 42, 44, 46, 48, 50, 52, 54) mounted thereto. The skilled artisan will of course appreciate, however, that the shield assembly 60 of the present invention may be advantageously employed in furnaces that have at least two electron beam guns mounted in adjacent relationship to each other such that the beams from the guns

may interact with each other. Therefore, the shield assembly 60 of the present invention should not be limited to use in connection with furnace arrangements that employ eight electron beam guns.

5 Figures 2 and 3 illustrate the layout of the electron beam guns (40, 42, 44, 46, 48, 50, 52, 54) in this embodiment. Figure 3 is a plan view of the melting zone 16 of the vacuum chamber 12. As can be seen therein, a barrier wall 17 separates the melting zone 16 into a first zone 19 10 and a second zone 21 and the center of the melting zone 16 is defined by axis A-A. Conventional electron beam guns (40, 42, 44, 46) are equally spaced along an axis B-B within the chamber 12. Axis B-B is substantially parallel to axis A-A. Likewise, conventional electron beam guns (48, 50, 52, 54) 15 are equally spaced along an axis C-C that is substantially parallel to axes A-A and B-B. Furthermore, in this embodiment, the centers of guns (40, 48) are aligned on an axis D-D that is substantially transverse to axis A-A. The centers of guns (52, 54) are aligned on an axis E-E that is 20 also substantially transverse to axis A-A. The centers of guns (44, 46) are offset from the centers of guns (52, 54).

One embodiment of the shield assembly 60 of the present invention is depicted in Figures 2 and 3. As can be seen in 25 Figure 3, the shield assembly 60 comprises a first assembly 62 that is adapted to be mounted within the first melting zone segment 19 and a second assembly 70 that is adapted to be mounted within the second melting zone segment 21. First

assembly 62 comprises a first longitudinal planar barrier 64 that may be fabricated from mild steel. A first transverse barrier 66, fabricated from mild steel may be attached to the first longitudinal barrier 64 by, for example, welding. As 5 can be seen in Figure 3, the first transverse barrier member 66 may be centrally disposed between guns (40, 42) (i.e., distance \mathbf{G} equals distance \mathbf{H}). First assembly 62 may further comprise a second transverse barrier member 68 fabricated from mild steel that may be attached to the first 10 longitudinal barrier member 62 by, for example, welding such that it is centrally disposed between the guns (48, 50) when installed (i.e., distance \mathbf{I} equals distance \mathbf{K}). As can be seen in Figure 2, the first and second transverse barriers (66, 68) are configured to substantially conform to 15 the contour of the corresponding ceiling portion 13 of the vacuum chamber 12 and the corresponding condensate frame assembly 30. The first shield segment 62 may be suspended from the corresponding condensate frame assembly with chain or wire. Those of ordinary skill in the art will appreciate 20 that the first shield assembly 62 may be attached to the corresponding condensate frame assembly 30 by bolted connections or other mechanical fasteners and connections. In addition, it will be further appreciated that the first 25 transverse barrier 66 and the second transverse barrier 68 do not have to be attached to the longitudinal barrier 62. Instead, the first transverse barrier 66 and the second transverse barrier 68 may be separately suspended or otherwise attached to the condensate frame assembly 30.

The second shield assembly 70 is adapted to be mounted within the second melting zone segment 21 and comprises a second longitudinal barrier 72 that may be fabricated from, for example, mild steel. A primary transverse barrier 74, 5 fabricated from, for example, mild steel may be attached to the second longitudinal barrier 72 by, for example, welding. As can be seen in Figure 3, the primary transverse barrier 74 may be centrally disposed between guns (44, 46) (i.e., distance $\frac{1}{2} L$ equals distance $\frac{1}{2} M$). The second shield 10 assembly 70 may further comprise a secondary transverse barrier member 76 fabricated from mild steel that may be attached to the second longitudinal barrier member 72 by, for example, welding such that it is centrally disposed between the guns (52, 54) when installed (i.e., distance $\frac{1}{2} N$ equals 15 distance $\frac{1}{2} O$). The primary and secondary transverse barriers (74, 76) are configured to substantially conform to the contour of the corresponding ceiling portion 13 of the vacuum chamber 12 and the corresponding condensate frame assembly 30. The second shield assembly 70 may be suspended 20 from the corresponding section of the condensate frame assembly 30 with chain, wire or other suitable material. Those of ordinary skill in the art will appreciate that the second shield assembly 70 may also be attached to the corresponding portions of condensate frame assembly 30 by 25 bolted connections or other mechanical fasteners and connections. In addition, it will be further appreciated that the primary transverse barrier 74 and the secondary transverse barrier 76 do not have to be attached to the

second longitudinal barrier 72. Instead, the primary transverse barrier 74 and the secondary transverse barrier 76 may be separately suspended or otherwise attached to the condensate frame assembly 30. It will be further 5 appreciated, however, that, in those furnace applications lacking the transverse barrier 17, the first and second longitudinal barriers (62, 72) may comprise a unitary member.

As can be seen in Figure 2, the electron beam guns (42, 44, 46, 48, 50, 52, 54) emit beams of electron particles 10 generally designated as 80. In this embodiment, the barriers (64, 66, 68, 72, 74, 76) extend downward toward the hearth assembly 20 from the condensate frame assembly 30 a distance of approximately 18 inches (45.7cm) (represented by arrow ΔP in Figure 1). Those of ordinary skill in the art will 15 appreciate that the distance that the shield assembly 60 protrudes downward is a function of the orientation of the electron beam guns. It is desirable for the shield assembly 60 to extend downward from the condensate shield assembly 30 as far as possible to minimize the amount of interaction 20 between the beams 80 of adjacent guns, but not so far such that the beams 80 begin to degrade and/or melt the barriers (64, 66, 68, 72, 74, 76). Such distance may be determined by installing plates of various sizes between the adjacent guns to determine the maximum distance that the barriers can 25 extend without being degraded or melted. In the embodiment depicted in Figures 1 and 2, the distance ΔP is approximately 18 inches (45.7cm). Angle ΔR is approximately 15° and angle ΔS is approximately 15° . It

is conceivable, however, that other distances and angles may be successfully employed.

Another embodiment of the shield assembly of the present invention is depicted in Figures 4-9. Figure 4 is a plan view of a portion of a condensate frame assembly 130 of an electron beam furnace 110 that corresponds to a section of the furnace that has four electron beam guns. Thus, the condensate frame assembly 130 has four gun ports (132, 134, 136, 138) therein. As can be seen in Figures 4-7, this embodiment of the shield assembly 160 comprises a longitudinal barrier 162 that is fabricated from, for example, mild steel. Also in this embodiment, first and second transverse plates (164, 166) may be attached together by, for example, welding to opposing sides of the longitudinal barrier 162. It will be appreciated, however, that the first and second transverse plates (164, 166) do not have to be attached to the longitudinal barrier, but may be separately suspended or otherwise attached to the condensate frame assembly 130. When installed, the longitudinal barrier 162 is centrally disposed between the gun ports (132, 134) and the gun ports (136, 138). The first and second transverse plates (164, 166) are centrally disposed between ports (132, 136) and ports (134, 138), respectively. See Figure 4. The end of the first transverse plate 164 may be approximately six inches (15.24cm) from the centerlines of gun ports (132, 134) (distance $\frac{1}{2} T_2$) and the end of the second transverse barrier 166 may be approximately six inches (15.24cm) from the centerlines of the gun ports (136, 138).

(distance ~~8~~ U~~8~~).

To facilitate removable attachment to the condensate frame assembly 130, superstructure hangers in the form of transverse hanger struts 180 fabricated from, for example, 5 mild steel, are attached to the longitudinal barrier 162 by pieces of steel angle 182 welded thereto. Those of ordinary skill in the art will appreciate that the hanger struts 180 may be attached to the longitudinal barrier 162 by a variety of different methods without departing from the spirit and 10 scope of the present invention. The struts 180 are oriented to correspond with cross members of the condensate frame assembly 130 to enable the struts 180 to be removably affixed thereto by chain or wire 182. However, the struts 180 may be attached to the condensate frame assembly 130 or the vacuum 15 chamber 112 by any suitable means including bolting, clamping, welding, etc.

As can be seen in Figure 9, additional barrier plates 190 may be affixed to each end of the frame assembly 130. To facilitate such attachment, a series of holes 192 may be 20 provided through the plate 190 to enable the plate 190 to be wired or chained to the frame assembly 130. The plate 190 may, however, be attached to the condensate frame assembly or vacuum chamber superstructure 13 by a variety of different fastening methods such as bolting or welding. As can also be 25 seen in Figure 9, the plates 190 may be provided with a relatively arcuate upper edge 196 to enable the plates to conform to the shape of the upper portion of the vacuum chamber 112 or the condensate frame assembly 130. In that

embodiment, the bottom of the barrier plate 190 coincides with the bottom of the condensate frame assembly 130.

Thus, from the foregoing discussion, it is apparent that the present invention may be used in connection with a 5 variety of different electron beam furnaces. The subject invention may be advantageously adapted to limit interaction of electron beams emitted from adjacent electron beam guns mounted within a furnace. In addition, because the shield assemblies are removably attached to the condensate screen 10 assemblies, they can be easily removed therefrom for cleaning purposes. It will be understood, however, that the shield assemblies of the present invention may be non-removably affixed to the condensate screen assembly or to the vacuum chamber itself, if so desired.

15 Accordingly, the present invention represents an easy and inexpensive method of limiting interaction of electron beams in an electron beam furnace. Those of ordinary skill in the art will, of course, appreciate that various changes in the details, materials and arrangement of parts which have 20 been herein described and illustrated in order to explain the nature of the invention may be made by the skilled artisan within the principle and scope of the invention as expressed in the appended claims.

What is claimed is:

1. Apparatus for limiting interaction between beams generated by at least two electron beam guns mounted within an 5 electron beam furnace having a superstructure, said apparatus comprising:

a planar barrier sized to extend between at least two electron beam guns; and

a superstructure hanger connected to said planar barrier.

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2. The apparatus of claim 1 wherein said planar barrier comprises a planar sheet fabricated from mild steel.

3. The apparatus of claim 1 wherein said superstructure 15 hanger comprises:

a plurality of holes in said planar barrier; and
at least one piece of fastener chain corresponding to each said hole.

20 4. The apparatus of claim 3 wherein said planar barrier has a substantially arcuate upper edge.

5. The apparatus of claim 1 wherein said superstructure hanger comprises at least two transverse struts attached to a 25 top edge of said planar barrier and extending transversely thereto.

6. Apparatus for limiting interaction between beams generated by at least two electron beam guns mounted within an electron beam furnace having a superstructure, said apparatus 5 comprising:

 a plate fabricated from mild steel;
 at least two cross braces affixed to an upper edge of said plate;
 at least one fastener hole in each said cross brace; and
10 a flexible fastener member corresponding to a fastener hole in a corresponding cross brace for attaching said corresponding cross brace to the superstructure.

7. Apparatus for limiting interaction between beams generated by two electron beam guns mounted within an electron beam furnace having a superstructure, said apparatus 15 comprising:

 means for establishing at least a partial barrier between the at least two electron beam guns; and
20 means for hanging said means for establishing from the superstructure such that said means for establishing is centrally disposed between the two electron beam guns and suspended therebetween a predetermined distance.

25 8. An electron beam furnace, comprising:

 a vacuum chamber having an upper portion and a lower

portion;

a hearth assembly within said lower portion of said vacuum chamber;

5 at least two electron beam guns mounted within said vacuum chamber above said hearth assembly; and

at least one planar barrier suspended from said upper portion of said vacuum chamber and extending between at least two said electron beam guns.

10 9. The electron beam furnace of claim 8 wherein each said planar barrier comprises a plate fabricated from mild steel.

10. The electron beam furnace of claim 8 further
15 comprising a framework within said vacuum chamber and wherein each said planar barrier is suspended from said framework by a flexible member.

11. The electron beam furnace of claim 10 wherein each
20 said planar barrier has at least two cross struts attached to an upper edge thereof and wherein said cross struts are wired to said framework.

12. The electron beam furnace of claim 8 wherein said
25 furnace has first and second pairs of electron beam guns and wherein said planar barrier is centrally disposed between said

first and said second pairs of electron beam guns.

13. Apparatus for limiting interaction between beams generated by electron beam guns mounted within the vacuum 5 chamber of an electron beam furnace, said apparatus comprising:

a longitudinal barrier suspendable within said vacuum chamber; and

a first transverse barrier attached to said longitudinal barrier and sized to extend between a first pair of electron 10 beam guns when suspended within the electron beam furnace.

14. The apparatus of claim 13 further comprising a second transverse barrier attached to said longitudinal barrier and extending between a second pair of electron beam guns.

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15. The apparatus of claim 14 wherein said longitudinal barrier and said first and second transverse barriers comprise planar plate members.

20 16. The apparatus of claim 15 wherein said planar plate members are fabricated from mild steel.

17. The apparatus of claim 13 wherein said first transverse barrier is centrally disposed between the two 25 electron beam guns of the first pair of electron beam guns.

18. The apparatus of claim 14 wherein said second transverse barrier is centrally disposed between the two electron beam guns of the second pair of electron beam guns.

5 19. The apparatus of claim 14 wherein said longitudinal barrier is centrally disposed between the first and second pairs of electron beam guns.

20. The apparatus of claim 14 wherein said first 10 transverse barrier is centrally disposed between the two electron beam guns comprising the first pair of electron beam guns and wherein said second transverse barrier is centrally disposed between the electron beam guns comprising the second pair of electron beam guns.

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21. The apparatus of claim 13 further comprising: a second longitudinal barrier suspendable within the vacuum chamber; and a primary transverse barrier member affixed to said second 20 longitudinal barrier member and extending between a third pair of electron beam guns.

22. The apparatus of claim 21 further comprising a secondary transverse barrier member affixed to said second 25 longitudinal barrier and extending between a fourth pair of electron beam guns.

23. The apparatus of claim 22 wherein said second longitudinal barrier is centrally disposed between said third and fourth pairs of electron beam guns.

5 24. The apparatus of claim 21 wherein said primary transverse barrier member is centrally disposed between the electron beam guns comprising the third pair of electron beam guns.

10 25. The apparatus of claim 22 wherein said secondary transverse barrier member is centrally disposed between the electron beam guns comprising the fourth pair of electron beam guns.

15 26. The apparatus of claim 22 wherein said primary transverse barrier member is centrally disposed between the electron beam guns comprising the third pair of electron beam guns and wherein said secondary transverse barrier member is centrally disposed between the electron beam guns comprising 20 the fourth pair of electron beam guns.

27. Apparatus for limiting interaction between beams generated by electron beam guns mounted within the vacuum chamber of an electron beam furnace, said apparatus comprising:
25 a longitudinal barrier suspendable within said vacuum chamber; and

a first transverse barrier suspendable adjacent to said longitudinal barrier and sized to extend between a first pair of electron beam guns when suspended within the electron beam furnace.

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28. The apparatus of claim 27 further comprising a second transverse barrier suspendable adjacent to said longitudinal barrier and sized to extend between a second pair of electron beam guns when suspended within the electron beam furnace.

10

29. The apparatus of claim 27 wherein said longitudinal barrier and said first and second transverse barriers comprise planar plate members.

15

30. The apparatus of claim 27 wherein said first transverse barrier is centrally disposed between the two electron beam guns of the first pair of electron beam guns.

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31. The apparatus of claim 28 wherein said second transverse barrier is centrally disposed between the two electron beam guns of the second pair of electron beam guns.

25

32. The apparatus of claim 28 wherein said longitudinal barrier is centrally disposed between the first and second pairs of electron beam guns.

33. The apparatus of claim 28 wherein said first transverse barrier is centrally disposed between the two electron beam guns comprising the first pair of electron beam guns and wherein said second transverse barrier is centrally 5 disposed between the electron beam guns comprising the second pair of electron beam guns.

34. The apparatus of claim 27 further comprising:
a second longitudinal barrier suspendable within the
10 vacuum chamber; and

a primary transverse barrier member suspendable adjacent to said second longitudinal barrier member and sized to extend between a third pair of electron beam guns when suspended within the electron beam furnace.

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35. The apparatus of claim 34 further comprising a secondary transverse barrier member suspendable adjacent to said second longitudinal barrier and sized to extend between a fourth pair of electron beam guns when suspended within the
20 electron beam furnace.

36. The apparatus of claim 35 wherein said second longitudinal barrier is centrally disposed between said third and fourth pairs of electron beam guns.

25

37. The apparatus of claim 34 wherein said primary

transverse barrier member is centrally disposed between the electron beam guns comprising the third pair of electron beam guns.

5 38. The apparatus of claim 35 wherein said secondary transverse barrier member is centrally disposed between the electron beam guns comprising the fourth pair of electron beam guns.

10 39. The apparatus of claim 35 wherein said primary transverse barrier member is centrally disposed between the electron beam guns comprising the third pair of electron beam guns and wherein said secondary transverse barrier member is centrally disposed between the electron beam guns comprising 15 the fourth pair of electron beam guns.

40. An electron beam furnace, comprising:
a vacuum chamber;
a hearth assembly within said vacuum chamber;
20 a first pair of electron beam guns affixed to said vacuum chamber for projecting electron beams towards said hearth assembly;
a second pair of electron beam guns affixed to said vacuum chamber for projecting electron beams towards said hearth 25 assembly; and
a planar barrier member suspended within said vacuum

chamber between said first and second pairs of electron beam guns.

41. The electron beam furnace of claim 40 wherein said 5 furnace has a longitudinal axis and wherein said planar barrier comprises a longitudinal barrier that is suspended along said longitudinal axis of said furnace.

42. The electron beam furnace of claim 41 further 10 comprising:

a first transverse barrier member supported adjacent to said longitudinal barrier and being centrally disposed between electron beam guns comprising said first pair of electron beam guns; and

15 a second transverse barrier member supported adjacent to said longitudinal barrier member and being centrally disposed between electron beam guns comprising said second pair of electron beam guns.

20 43. The electron beam furnace of claim 42 wherein said first and second transverse barriers are attached to said longitudinal barrier.

44. The electron beam furnace of claim 43 wherein said 25 vacuum chamber defines a melting zone having a first melting zone segment and a second melting zone segment and wherein said

hearth assembly extends through said first and second melting zone segments and wherein said first and second pairs of electron beam guns are oriented to project electron beams on said hearth assembly within said first melting zone segment.

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45. The electron beam furnace of claim 44 wherein said furnace further comprises:

a third pair of electron beam guns affixed to said vacuum chamber for projecting electron beams towards said hearth assembly within said second melting zone segment;

a fourth pair of electron beam guns affixed to said vacuum chamber for projecting electron beams towards said hearth assembly within said second melting zone segment; and

a second longitudinal barrier suspended within said second melting zone segment between said third and fourth pairs of electron beam guns.

46. The electron beam furnace of claim 45 further comprising:

20 a primary transverse barrier member affixed to said second longitudinal barrier and being centrally disposed between electron beam guns comprising said third pair of electron beam guns; and

25 a secondary transverse barrier member affixed to said second longitudinal barrier member and being centrally disposed between electron beam guns comprising said fourth pair of

electron beam guns.

47. A method for limiting interaction between electron beams generated by at least two electron beam guns within a 5 vacuum chamber of an electron beam furnace, comprising suspending a barrier from an upper portion of the vacuum chamber such that the barrier extends between the electron beams produced by the at least two electron beam guns.

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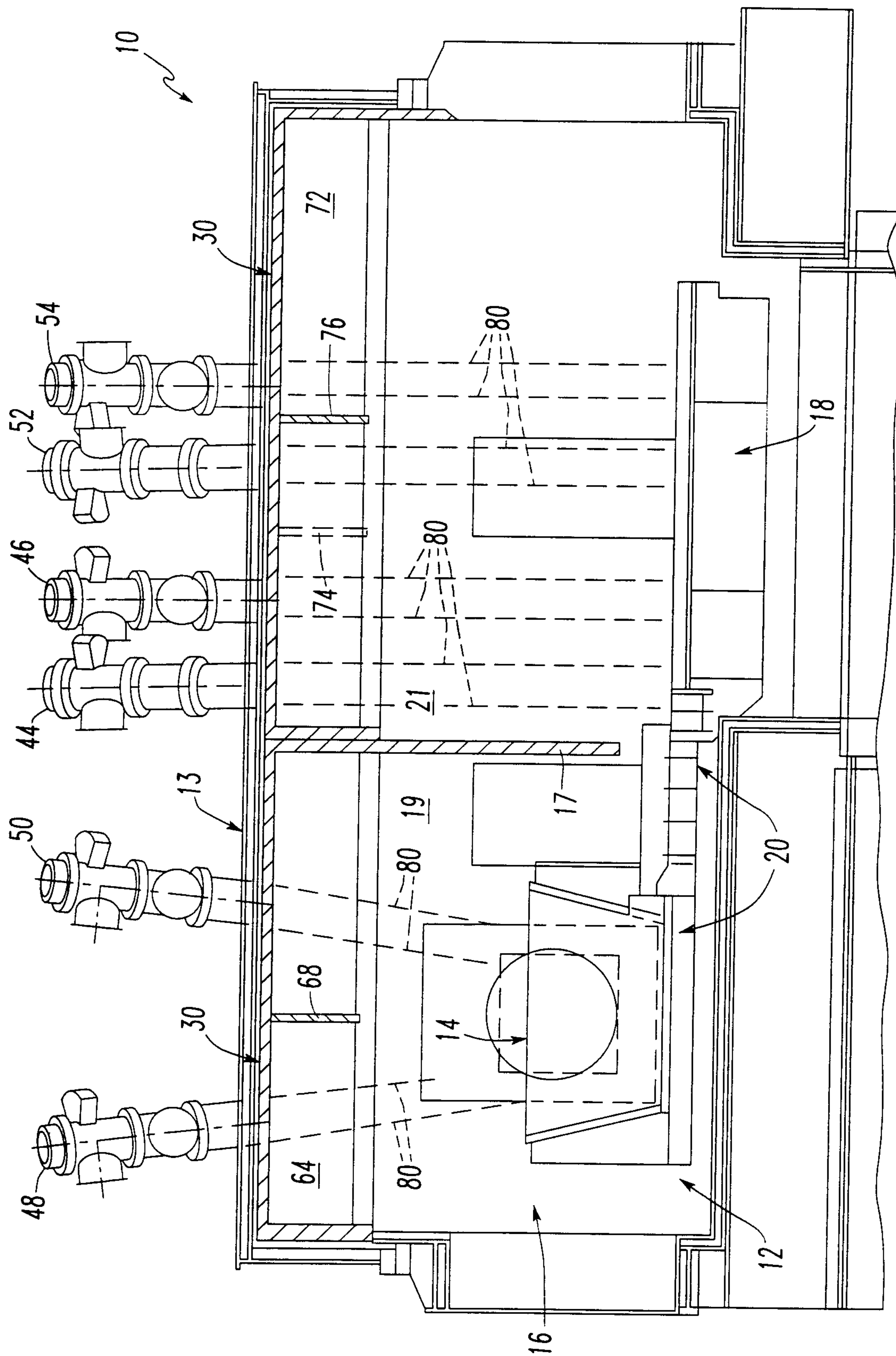


FIG. 1

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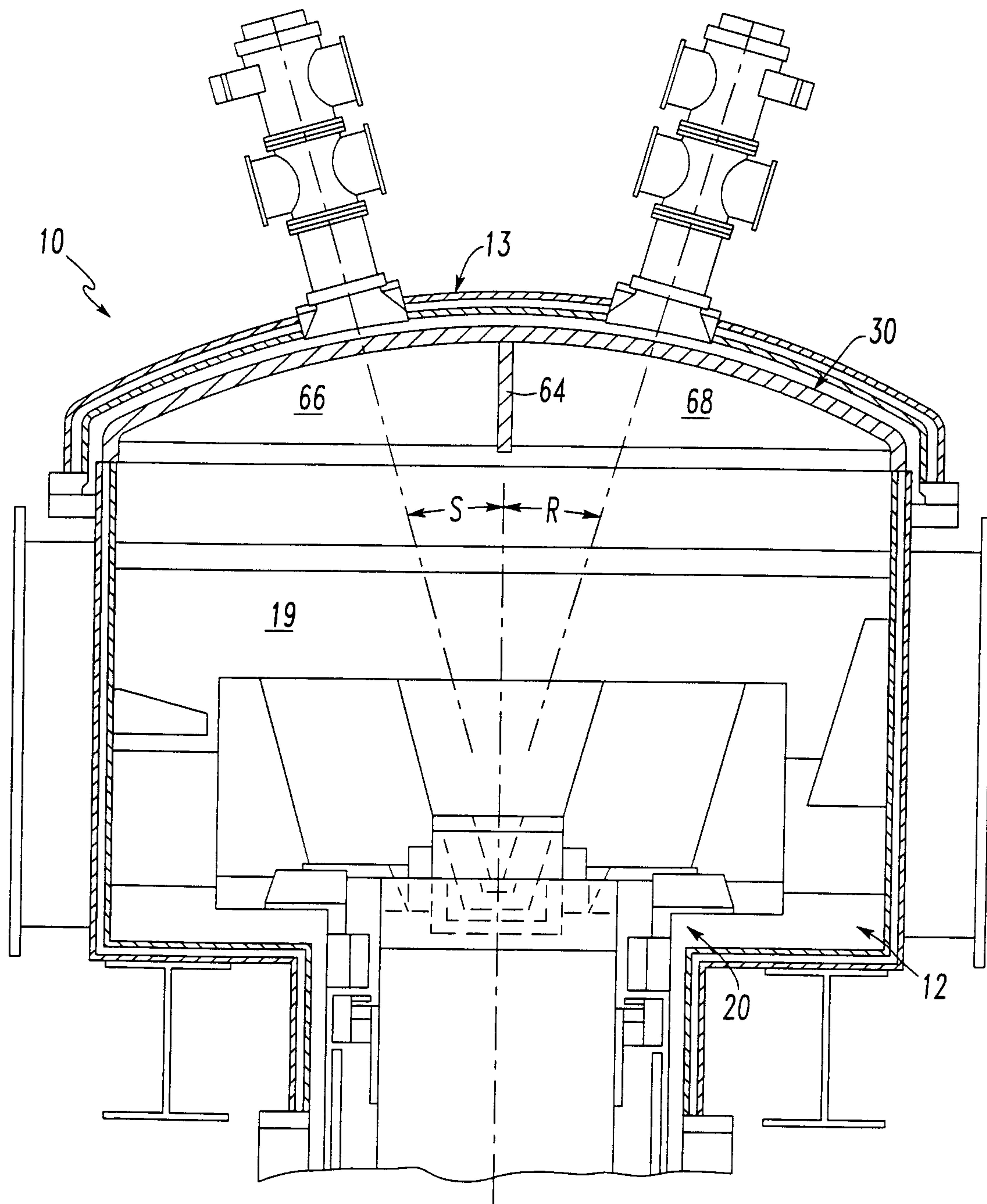


FIG. 2

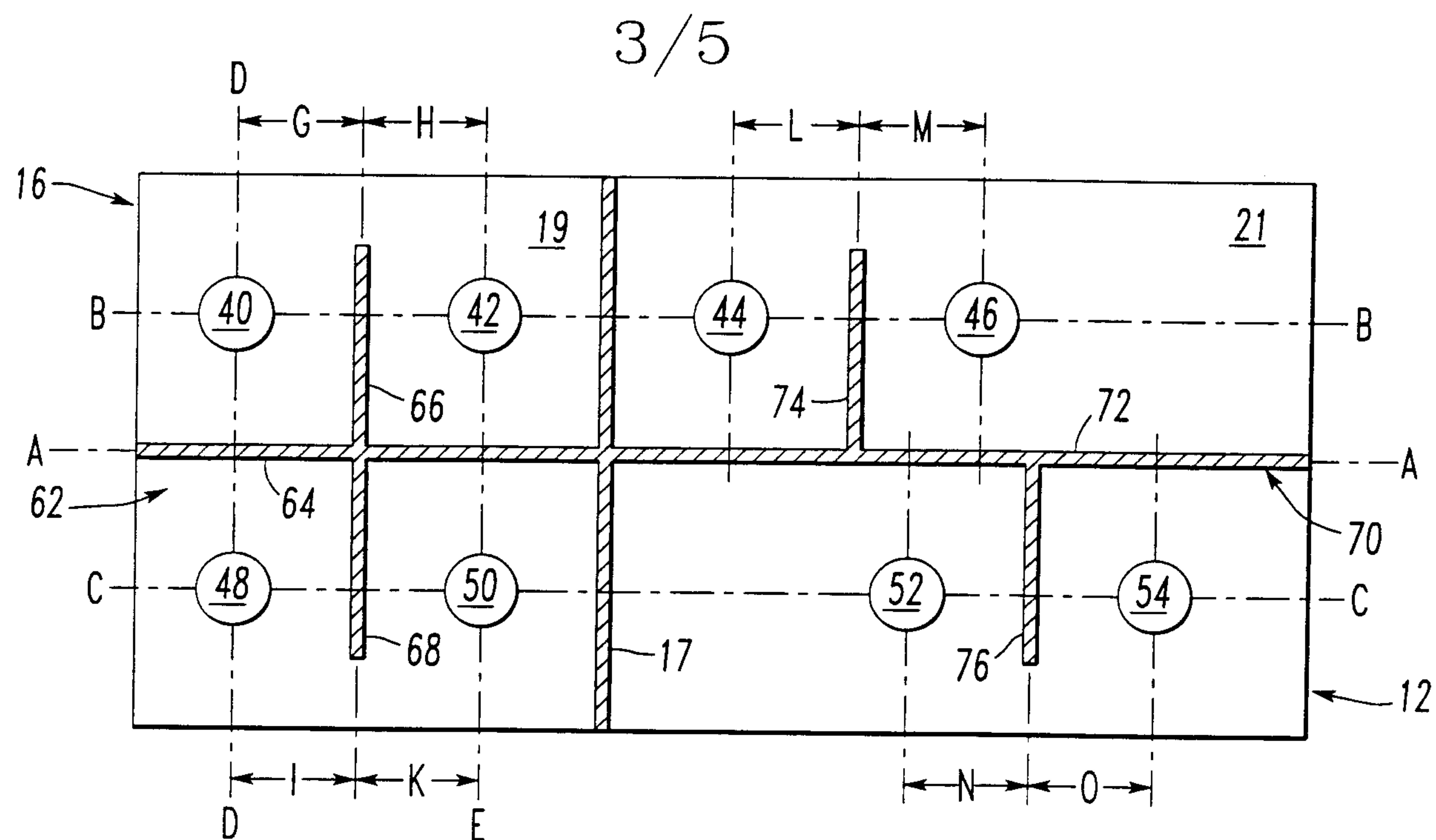


FIG. 3

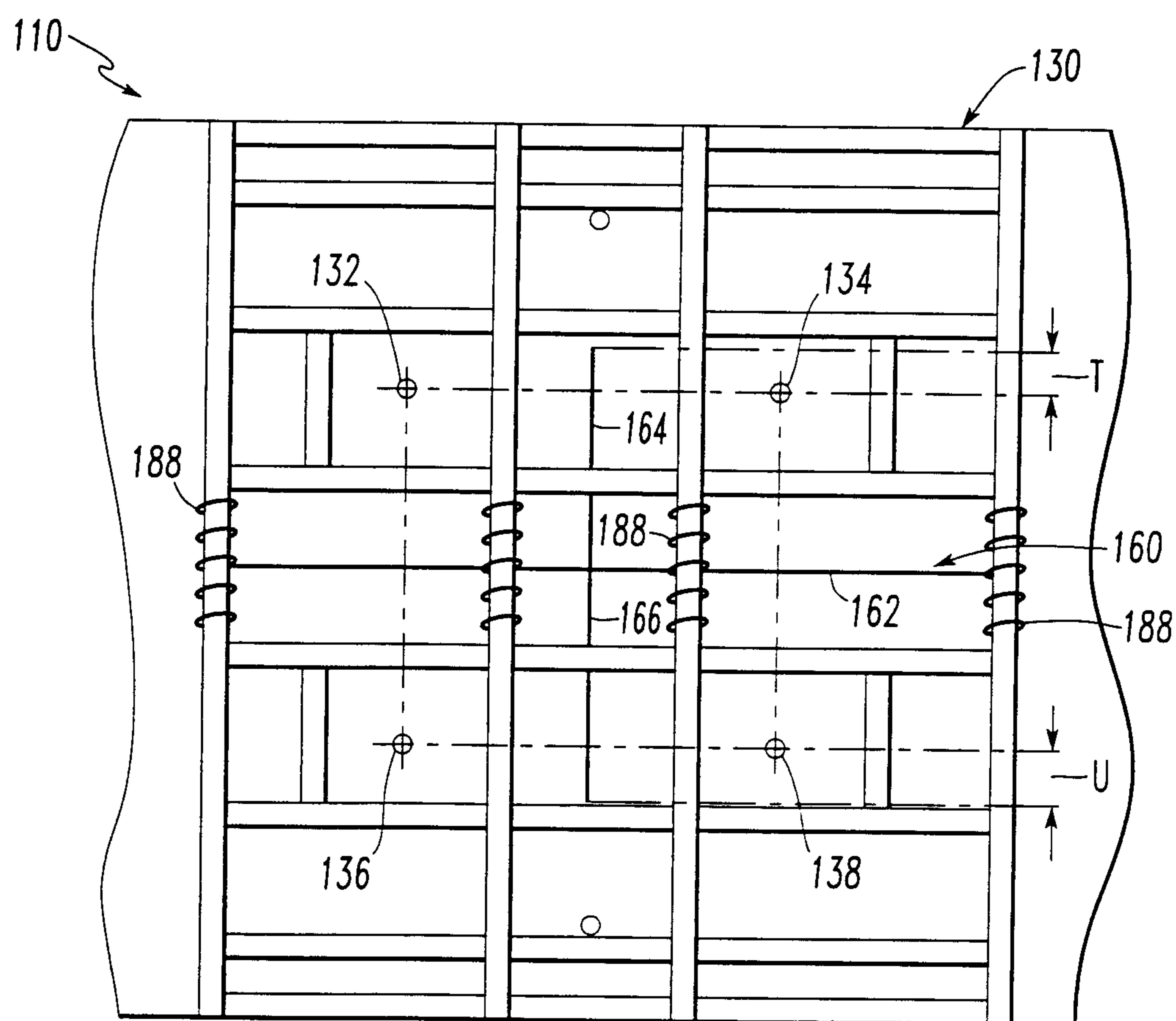


FIG. 4

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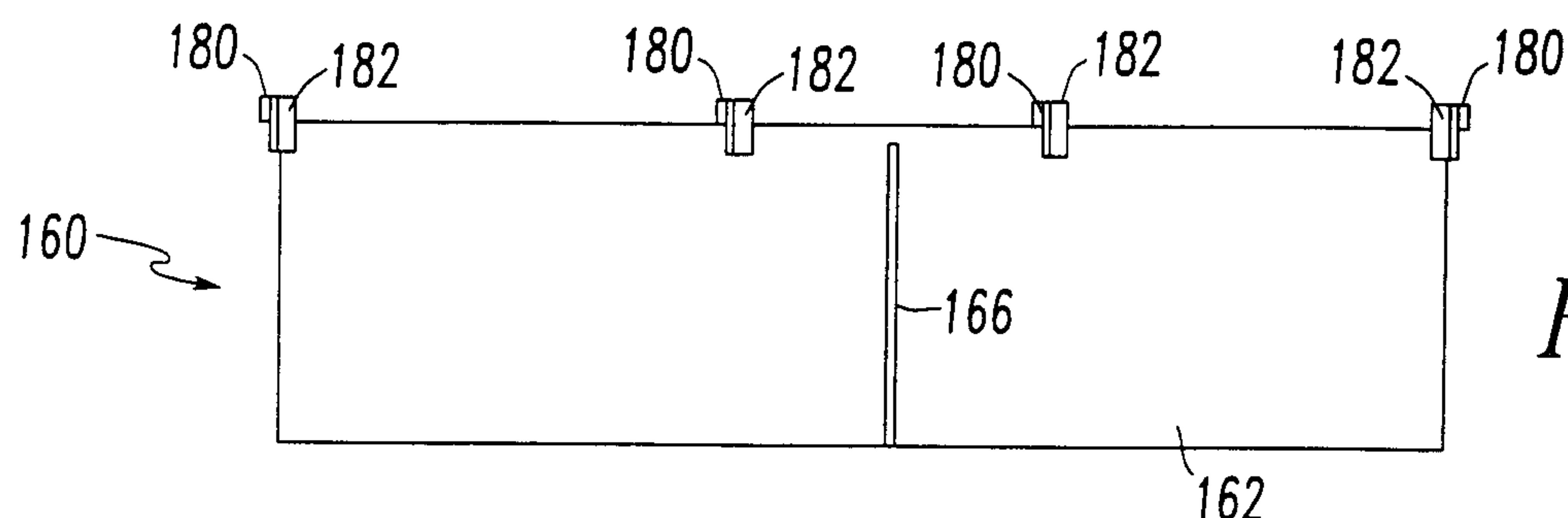


FIG. 5

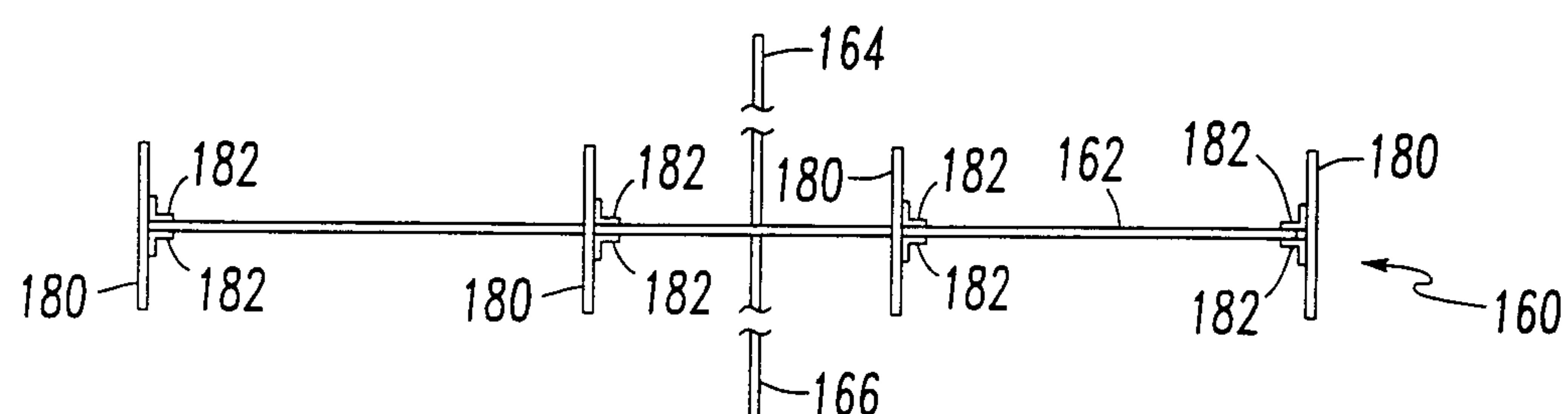


FIG. 6

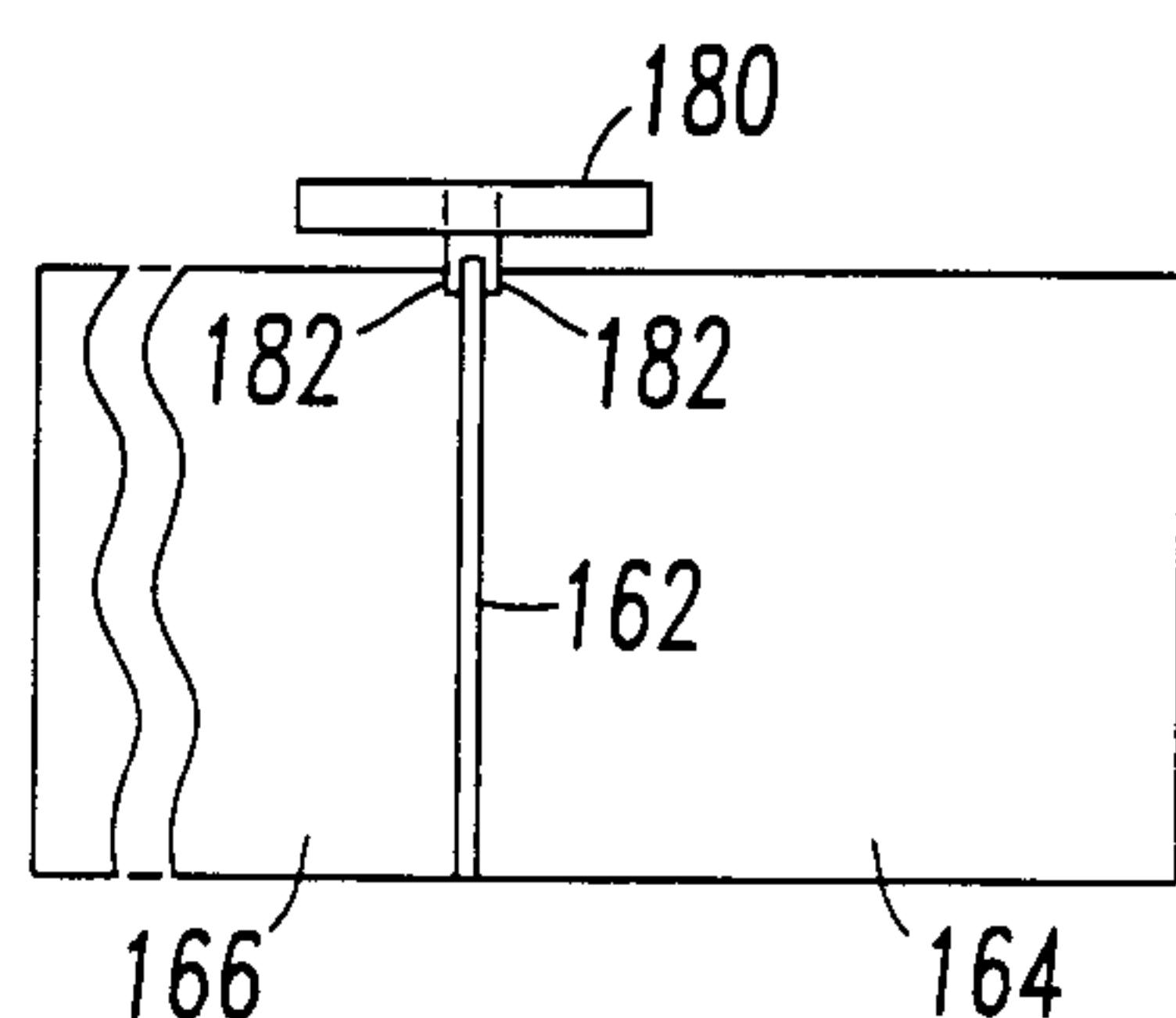


FIG. 7

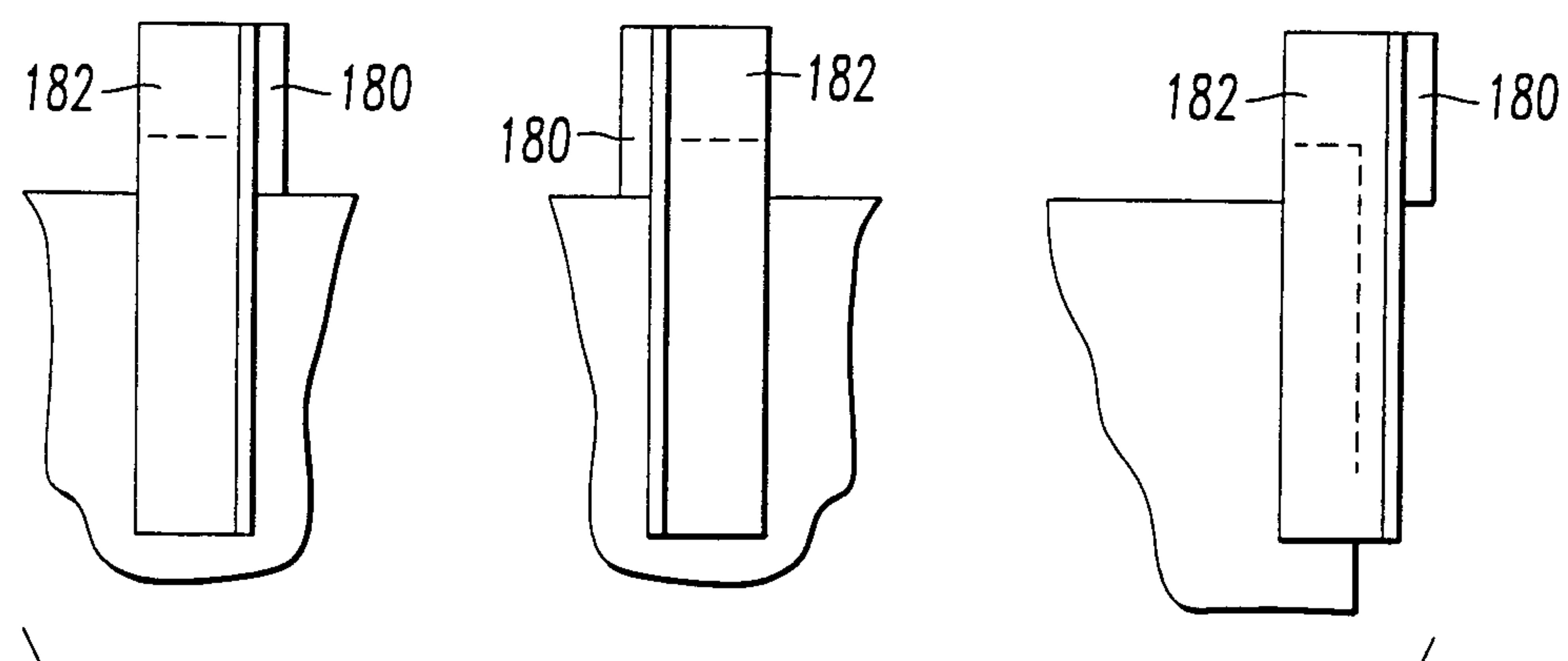


FIG. 8

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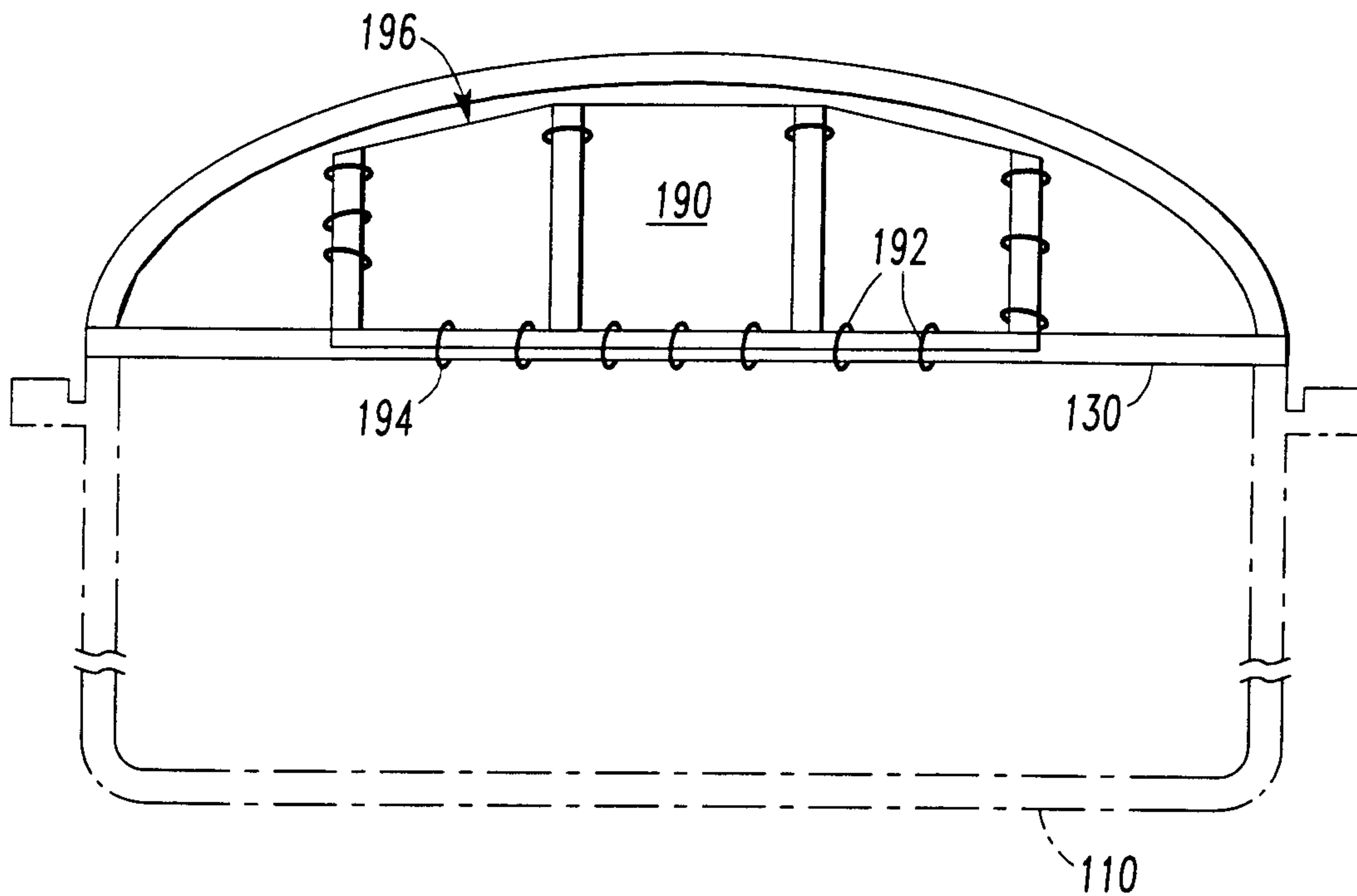


FIG. 9

